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Linearization of a two-axis MEMS scanner driven by vertical comb-drive actuators

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Abstract

A driving scheme using a pair of differential voltages (V_x , V_y) over a bias voltage is proposed to linearize the dc characteristic (angle versus voltage) of a two-axis MEMS scanner. The micromirror has a gimbal-less structure and is driven by vertical comb-drive actuators in conjunction with a leverage mechanism. At an optimal bias voltage of 53 V, a linear optical scan range of $\pm 3.2^\circ$ is achieved experimentally in both the x and y directions with the differential voltages ranging from -10 V to $+10$ V.

(Some figures in this article are in colour only in the electronic version)

1. Introduction

MEMS (micro-electro-mechanical systems) scanners have been widely adopted in a variety of photonics-related research fields or products. In telecommunications, they are the key enabling components for two-dimensional (2D) [1] and three-dimensional (3D) [2, 3] optical cross-connects (OXCs), dynamic gain equalizers [4, 5], wavelength add-drop multiplexers (WADMs) [6, 7] and wavelength-selective switches (WSSs) [8–10]. They offer low optical insertion loss and crosstalk, independent of polarization and wavelength, as well as optical transparency for bit rate and data format. In adaptive optics, tip-tilt-piston micromirror arrays [11] and deformable mirrors [12] compensate wavefront distortions introduced by the medium and help achieve sharper images approaching the diffraction limit, which is particularly vital for space observation. MEMS optical scanners are also widely used in projection displays such as digital light processing [13] and laser scanning displays [14], endoscopic imaging [15] and confocal microscopy [16].

Electrostatic actuation is one of the most popular driving mechanisms for MEMS scanning mirrors [17]. Typically,

capacitive structures are embedded to generate the required electrostatic torque for mirror rotation. The electrostatic torque, explicitly as a function of V^2 , does not linearly vary with the actuation voltage. This results in strong distortion of the scan pattern when driving with linearly ramped voltages. In some cases, nonlinearity in the capacitance gradient with respect to rotation angle (θ) further aggravates the distortion; for instance, the capacitance of a parallel-plate scanner exhibits $1/\theta$ dependence.

Several approaches have been proposed to eliminate the distortion, resulting in scan patterns with high linearity. Chiou *et al* divided the bottom electrode into multiple segments to fulfil the linearization of a one-axis parallel-plate micromirror [18]. Hiroshi *et al* demonstrated the linearization of a two-axis parallel-plate MEMS scanner by using a differential-voltage driving scheme, which was relatively simple and could be realized in open-loop operation [19]. The two polarities of the differential voltage V_{diff} were superimposed on a bias voltage V_{bias} . The resulting sum voltages, $(V_{\text{bias}} + V_{\text{diff}})$ and $(V_{\text{bias}} - V_{\text{diff}})$, were applied on the opposite electrodes. This induced electrostatic torques in opposite directions and proportional to $(V_{\text{bias}} + V_{\text{diff}})^2$ and $(V_{\text{bias}} - V_{\text{diff}})^2$, respectively,

Figure 1. Comparison between parallel-plate and vertical comb-drive scanners.

on the mirror. The square terms V_{bias}^2 and V_{diff}^2 were cancelled out and only the term $V_{\text{bias}} \times V_{\text{diff}}$ remains in the net electrostatic torque, which is hence proportional to the control differential voltage V_{diff} under a constant bias. Moreover, PID control (by Zhao *et al* [20]) and neural network methods (by Zhao *et al* [21]) have been respectively incorporated with the differential-voltage driving scheme to further enhance the scanner linearity.

The differential driving scheme performs best on the occasion that the capacitance derivative with respect to the rotation angle ($\partial C/\partial \theta$) remains constant, which unfortunately is not the case for parallel-plate scanners. On the other hand, vertical comb-drive actuators, whose $\partial C/\partial \theta$ can be considered quasi-constant, seemingly prevail in this regard. However, the approach with differential-voltage driving is typically not suitable for rotating mirrors powered by vertical comb-drive actuators. This is due to the fact that, at the side that travels upward during rotation, the movable comb parts away from the fixed comb and their overlap vanishes at large angles. The consequence is that an opposite torque fails to be established, contrary to the case of parallel-plate scanners. This can be explained in figure 1.

Recently, we have proposed a novel two-axis analog micromirror powered by vertical comb-drive actuators in conjunction with leverage mechanism [22] (figure 2). Large mechanical rotation angles ($\pm 6.7^\circ$ for both axes at 75 V)

Figure 2. Schematic of the two-axis MEMS scanner driven by vertical comb-drive actuators in conjunction with a leverage mechanism [22].

Figure 3. Simulation model. The unit for the numbers in this figure is μm .

Figure 4. Lever characteristic: angle versus voltage, vertical displacement of the lever-mirror joint versus voltage.

and high resonant frequency (5.9 kHz before metallization) were achieved experimentally. The device was manufactured through a five-layer surface-micromachining process offered by Sandia National Laboratory. It can also be replicated along the x direction to form a high fill-factor 1D mirror array [22].

Figure 5. Distribution of $E_{f,\text{total}}$ under different bias voltages: (a) $V_{\text{bias}} = 20$ V, (b) $V_{\text{bias}} = 30$ V, (c) $V_{\text{bias}} = 40$ V, (d) $V_{\text{bias}} = 50$ V and (e) $V_{\text{bias}} = 53$ V.

The mirror is equipped with four lever-comb-drive pairs and the design architecture ensures that all the four electrodes contribute toward the mirror rotation under any circumstance. Therefore, a differential driving scheme becomes possible for a comb-drive-driven mirror constructed in this manner. However, one has to note that the fundamental principle

of differential driving of such a comb-drive-lever mirror is different from that of a parallel-plate scanner. As mentioned above, in the differential driving scheme of a parallel-plate mirror, electrostatic torques in the opposite directions are generated to cancel out the quadratic nonlinear terms. In our device, however, each comb-drive-powered lever possesses

Figure 6. x - y plane projections of $E_{f,\text{total}}$ for (a) $V_{\text{bias}} = 20$ V, (b) $V_{\text{bias}} = 30$ V, (c) $V_{\text{bias}} = 40$ V, (d) $V_{\text{bias}} = 50$ V and (e) $V_{\text{bias}} = 53$ V, where the values greater than 0.1 are discarded. The red square is the largest square scan pattern that has its sides aligned parallel/orthogonally to the axes and is enclosed by the projection image.

control over the motion of one mirror corner. By measuring the angle–voltage characteristic of each lever, we are able to determine the optimal bias point to achieve the maximum scan pattern that exhibits high linearity using open-loop operation.

2. Simulation determining the optimal bias point

2.1. Model

At most four independent voltages can be allowed to operate our comb-drive-lever mirror. The voltages applied on the four

Figure 7. Schematic of the experimental setup.

levers are denoted as V_1 , V_2 , V_3 and V_4 , respectively. We further express them as

$$\begin{aligned} V_1 &= V_{\text{bias}} + v_1 \\ V_2 &= V_{\text{bias}} + v_2 \\ V_3 &= V_{\text{bias}} + v_3 \\ V_4 &= V_{\text{bias}} + v_4. \end{aligned} \quad (1)$$

In figure 3, we define the coordinate of the mirror center as $(0, 0, z_{\text{bias}})$, where z_{bias} represents the lift of the mirror center and is determined by the bias voltage V_{bias} . The coordinates of the four lever-mirror joints are $(50 \mu\text{m}, 50 \mu\text{m}, z_{\text{bias}} + z_1)$, $(-50 \mu\text{m}, 50 \mu\text{m}, z_{\text{bias}} + z_2)$, $(-50 \mu\text{m}, -50 \mu\text{m}, z_{\text{bias}} + z_3)$, and $(50 \mu\text{m}, -50 \mu\text{m}, z_{\text{bias}} + z_4)$, where z_1 , z_2 , z_3 and z_4 are determined by v_1 , v_2 , v_3 and v_4 , respectively. f is the distance between the mirror and the observation plane. For an incident light in the direction of $(0, 0, -1)$ to be reflected to a point (x, y) on the observation plane, the MEMS mirror has to be rotated so that its normal vector becomes $(x/2, y/2, f)$ as depicted in figure 3. For each targeted point on the observation plane, a combination of (z_1, z_2, z_3, z_4) and a corresponding (v_1, v_2, v_3, v_4) set can be solved. The step-by-step procedure is as follows:

- (1) Experimentally measure the angle versus voltage curve of the lever and, hence, the vertical displacement of the lever-mirror joint versus voltage.
- (2) Set a bias voltage V_{bias} for all levers, which then determines z_{bias} according to the curve obtained in step 1.
- (3) Define the scan range and an array of targeted (x, y) points on the observation plane.
- (4) Find the mirror normal vector n for the light to be reflected to a certain point (x, y) .
- (5) For each n , find z_1 , z_2 , z_3 and z_4 . Then the solution for (v_1, v_2, v_3, v_4) can be obtained using the curve in step 1 along with V_{bias} and z_{bias} . (v_1, v_2, v_3, v_4) is considered as the control voltage set.

Table 1. Spans of the square patterns in figure 6: scan field size on the observation plane and the corresponding optical scan angle.

Bias voltage (V)	Scan field size on the observation plane (μm^2)	Optical scan angle in the x and y directions ($^\circ$)
20	200×200	± 0.14
30	530×530	± 0.38
40	1800×1800	± 1.3
50	1670×1670	± 1.2
53	5900×5900	± 4.22

Generally fewer independent voltages are preferred as the control scheme can then be simplified. For a two-axis scanner, at least two independent voltages, typically denoted as V_x and V_y , are required. Our purpose is therefore to reduce (v_1, v_2, v_3, v_4) to (V_x, V_y) , i.e. to express v_1 , v_2 , v_3 and v_4 as linear combinations of V_x and V_y as follows:

$$\begin{aligned} v_1 &= \frac{1}{2} \cdot (V_x + V_y) \\ v_2 &= \frac{1}{2} \cdot (-V_x + V_y) \\ v_3 &= \frac{1}{2} \cdot (-V_x - V_y) \\ v_4 &= \frac{1}{2} \cdot (V_x - V_y). \end{aligned} \quad (2)$$

At any given bias voltage, V_x and V_y can be solved only for the solutions in which $v_1 = -v_3$ and $v_2 = -v_4$. Therefore, we define the error functions as

$$E_{f1} = \frac{|v_2| - |v_4|}{|v_2| + |v_4|}, \quad E_{f2} = \frac{|v_1| - |v_3|}{|v_1| + |v_3|}, \quad (3)$$

and

$$E_{f,\text{total}} = E_{f1} + E_{f2}. \quad (4)$$

E_{f1} and E_{f2} , each of which can actually be viewed as a ratio of the voltage difference to the average voltage, represent the degrees of $V_2 - V_4$ and $V_1 - V_3$ discrepancies, respectively. Ideally $E_{f,\text{total}}$ has to be 0 for exactly solving V_x and V_y ; however, we hereby define a tolerance 0.1 such that V_x and V_y are said to be ‘quasi-solved’ for $E_{f,\text{total}} < 0.1$ (i.e., 10%). V_x and V_y are then experimentally superimposed on the bias voltage V_{bias} according to equations (1) and (2) so

Figure 8. Scan fields measured by the PSD under different bias voltages: (a) $V_{\text{bias}} = 20\text{ V}$, (b) $V_{\text{bias}} = 30\text{ V}$, (c) $V_{\text{bias}} = 40\text{ V}$, (d) $V_{\text{bias}} = 50\text{ V}$ and (e) $V_{\text{bias}} = 53\text{ V}$.

that a differential driving scheme can be achieved for two-axis rotation.

The coordinate axes in figures 2 and 3 are defined in a way that the x and y axes are parallel and orthogonal to

the mirror array direction, respectively. This is mainly for the convenience of application and is adopted throughout the paper. However, it is worth noting that the coordinate axes can also be set along the mirror diagonals, i.e. 45° rotation of the

Figure 9. Effect of lens aberration on the measured scan pattern.

current coordinate system. In this case the lever-mirror joints are situated right on the axes. There is then no need to use the linear combinations of V_x and V_y in the differential driving scheme, i.e. they can be superimposed on the bias voltage separately.

2.2. Simulation results

Figure 4 is the measured individual lever characteristic. Simulations are done under various bias voltages. The distance between the mirror and the observation plane is set as 4 cm, which is the focal length of the achromatic doublet lens used in the experiment. The experimental setup will be explained in the next section. The distributions of $E_{f,\text{total}}$ under different bias voltages, 20 V, 30 V, 40 V, 50 V and 53 V, are plotted in figure 5. The x - y plane projections of $E_{f,\text{total}}$ are shown in figure 6, where the values greater than 0.1 are discarded. For each bias voltage, the largest square scan pattern that has its sides aligned parallel/orthogonally to the axes and is enclosed by the projection image is drawn with red solid lines. It is worth mentioning that at any given bias voltage some target points on the observation plane eventually yield solutions in which the resultant $z_{\text{bias}} + z_i$ ($i = 1, 2, 3$ or 4) either goes beyond the maximum displacement in figure 4 or falls below 0. Although these solutions have no physical meaning, the voltages (v_i) and error-function values are nevertheless mathematically calculated by means of extrapolation on the curve in figure 4. After defining the square scan patterns in figure 6, the solutions within the squares are rechecked to ensure that they do not fall within the aforementioned physically meaningless regime. Table 1 summarizes the spans of the square patterns in terms of the scan field size on the observation plane and the corresponding optical scan angle. It is concluded that the maximum scan range achievable by two independent control voltages occurs at $V_{\text{bias}} = 53$ V. The optical scan range starts to decrease beyond this point. At $V_{\text{bias}} = 60$ V (not shown in the figures), it becomes $\pm 0.6^\circ$.

3. Experiments

3.1. Differential driving operation

A schematic of the experimental setup is shown in figure 7. A 632.8 nm He-Ne laser is incident on the 50/50 beam splitter with a 45° incident angle. The laser beam ($1/e^2$ beam diameter $2w = 0.75$ mm) is then focused onto the MEMS

Figure 10. Non-differential driving scheme. The unit for the numbers in this figure is μm .

scanner by an achromatic doublet lens with 4 cm focal length, resulting in a focus spot size of $2w = 43 \mu\text{m}$. The differential voltages, V_x and V_y , are computer programmed and the bias voltage is provided by a power supply. The MEMS scanner deflects the laser beam, which is then recollimated by the achromatic doublet lens, passes through the beam splitter, and finally is collected by the position-sensing detector (PSD). This arrangement ensures the scan pattern be independent of the distance between the PSD and the lens.

The differential voltages are varied with an increment of 1 V and are limited within ± 10 V by the data acquisition (DAQ) card. Figure 8 shows the scan fields experimentally measured by the PSD under different biases in the differential-driving scheme. The scan range for $V_{\text{bias}} = 53$ V is limited to $\pm 3.2^\circ$ (in both the x and y directions) by the maximum voltage magnitude which can be provided by the DAQ card. It is expected that the value predicted by the simulation can be reached if sufficient driving voltage is supplied. We note that the required voltages to reach a certain angle in the experiment are larger than those in the simulation. This may result from the resistance at the lever-mirror joints, which are elastic and compliant, but actually not completely free.

The larger scan pattern for $V_{\text{bias}} = 53$ V exhibits distortion with a barrel shape, mainly caused by the lens aberration. The effect of lens aberration can be explained with the model in figure 9 constructed using ZEMAX, a commercial ray tracing software. A point source on the left focal plane emerging optical rays can be treated as the MEMS mirror steering the laser beam, where each ray is viewed as the reflected light beam from the mirror poised at a certain tilt angle. A $0.45 \text{ cm} \times 0.45 \text{ cm}$ square aperture, corresponding to the mirror scan pattern for $V_{\text{bias}} = 53$ V, is placed right on the left of the lens. The transformed pattern at the PSD, 15 cm on the right of the lens, turns out to be a barrel shape due to the aberration of the achromatic doublet lens.

3.2. Non-differential driving operation

For comparison, a non-differential driving scheme with two independent voltages, V_x and V_y , is implemented. The voltage combination shown in figure 10 deflects the laser beam toward the 3rd quadrant. In our experiment, V_x and V_y both vary from 0 to 16.5 V with an increment of 1.65 V. This is achieved by

Figure 11. Scan field measured by the PSD under the non-differential driving scheme.

using power amplifiers for the voltages output by the computer. Similar voltage combinations can be used for beam deflection toward the 1st, 2nd and 4th quadrants. The complete scan pattern is shown in figure 11. It can be seen that the pattern is profoundly distorted even with a small optical scan range of $\leq \pm 0.3^\circ$. The slight asymmetry is due to optical system misalignment and the non-uniformity among levers.

4. Conclusions

We have implemented a differential driving scheme to linearize the dc characteristic of a two-axis MEMS scanner. The gimbal-less micromirror is driven by vertical comb-drive actuators in conjunction with leverage mechanism. A simulation model is developed to determine the maximum scan range. At an optimal bias voltage of 53 V, a linear optical scan range of $\pm 3.2^\circ$ is achieved experimentally in both the x and y directions with the differential voltages varying within the range of ± 10 V. It is expected that the value predicted by the simulation ($\pm 4.22^\circ$) can be approached if sufficient driving voltage is supplied.

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